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PATENT Customer ID: 25094

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Martin E. Kordesch et al.

ZApplication No.

09/682,151

Filing Date:

July 27, 2001

Group Art Unit:

2815

Examiner:

Chu, Chris C.

Title:

APR 1 8 2002

CONTACT METHOD FOR THIN SILICON CARBIDE EPITAXIAL LAYER AND SEMICONDUCTOR DEVICES FORMED BY THOSE METHODS

Certification Under 37 C.F.R. § 1.8

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to Commissioner for Patents, Washington, D.C. 20231, on V

2002.

Williams Carolyn J.

Dear Sir:

AMENDMENT

This Amendment is filed in regard to United States Patent Application No. 09/682 entitled "Contact Method for Thin Silicon Carbide Epitaxial Layer and Semiconductor Devic Formed by Those Methods" filed July 27, 2001. Please enter this Amendment into the carren Application.

IN THE SPECIFICATION:

Commissioner for Patents

Washington, D.C. 20231

Please insert the following paragraph on page 1 before "BACKGROUND OF INVENTION":

GOVERNMENTAL RIGHTS

The U.S. Government has a paid-up license in this invention and the right in limited circumstances to require the patent owner to license others on reasonable terms as provided by the terms of F33615-01-C-1602 awarded by the Air Force Research Laboratory.